

Details are important

How can the designer help to make cleaning assemblies easy?

Vladimir Sitko Founder, menthor of PBT Works s.r.o.





Course in the other day

Town of Rožnov - Czechia

Electronics production since 1948

Tesla Rožnov had 8500 employees until 1990

Reliability through cleaning - challenges

IS THAT CLEAN ?

Reliability through cleaning - challenges

NO !!!

Consequences of uncomplete cleaning





Leakage current



Pictures made by MAGNALYTICS inc. Glass test boards by PBT Works s.r.o.



Shortage by dendrite



Typical progress in washing the gap



Typically, gaps are 100% filled with flux residues Spray-in-air technology – direct spray against the surface Washing speed factors:

- Solubility flux/ cleaner
- Temperature, flow/ pressure, concentration, saturation (NVR), alkaline reserve
- **Gap geometry** kinetic energy transfer efficiency.

Gap size under component is essential



Pad thickness ≥ Solder mask thickness

Solder thickness \approx Printed solder thickness /2 - reduction by weight of the component

Ceramic and metal housings reduce solder thickness

Too thick solder mask



Gap reduced to zero !

Not cleanable with any process !



Tombstone caused by too thick solder mask

Reduced solder thickness



Rounded terminals are critical – package *"* dives" more deeply into the solder



Before cleaning



After cleaning



Tilted SOD123FL – package not astable due to narrow terminal and high point of gravity





Gap reduced to < 10um

After cleaning

Design induced obstacles



Line under component makes cleaning difficult.

Total reduction of gap by two broad lines.

Design failure – pads do not match with component terminals





Bottom of SOT223



In polarised light – flux residues





Solder wicks along the lug, but does not wett the solder mask

Cleaning obstacles on the package



Protrusion for assembly by SMT glue Today, mostly not needed. Lowers the gap for 80% !



Gap between terminal and bottom <10um - difficult to clean

For smaller tantalum capacitors with continuous flux spot between poles

- challenge for cleaning

Capacitors with central side terminal





Challenged for cleaning

Good for cleaning !

Reverse format chips







Reverse geometry combined with the line under the chip



Skipping solder mask can help...





...but, not at all circumstances

Shape of the gap is important

• Simulation on glass test boards







The same thickness of the gap The same width of the gap

2x longer gap3x longer cleaning time needed !

Shadowing by components



Components placed closely together reflect some portion of the spray beam by the top side of the package.

This energy is missing for cleaning the gap. Cleaning such configuration takes much longer



The shadowing effect can be suppressed

Direct spray against surface

- bidirectional (cleaning progress on the GTB)





Tangential spray

- single direction spray (cleaning progress on the GTB)



Large area gaps – doughter boards (modules)



Minimum gap size for daughter board Our experience:

gap - 5% of the largest dimension



Result of too small gap height Daughter board size 13mm, gap 60um

BGA, CSP, flip – chip



BGA does not compromise cleaning



NSMDP - non solder mask defined pad



SMDP - solder mask defined pad



CSP cleaned – ball size 150um



SMDP helps to lift the chip. It makes cleaning easier

BGA with irregular ball matrix







Chips under BGA – cleaning challenge

Irregularities in ball placement disturb liquid flow under BGA. Kinetic energy drops down. Results in uncomplete cleaning of residues (white residues)

QFN and similar BTC (LGA)





Gap size determined by amount of solder past on the termal lug - more paste – higher gap But – more solder paste – more residues + not termally processed !

Average gaps – 20 – 40um

Residues under BTC are critical for ECM

- Residues cannot degass properly "cubic flux"
 - Some volatile compounds remaind in the residues
 - Residues more susceptible to electrochemical migration (ECM)





Ms. Karen Lellefsen Presented at SMTA international, 2020

How to improve cleanability of QFN?

• Increasing the gap







SMDP (solder mask defined pad) Small gap Difficult to degas Difficult to clean

NSM (non solder mask) Higher gap Still difficult to degas Easier to clean



NSMDP (non solder mask defined pad) Highest gap Easier to degas Easier to clean

How to improve cleanability of QFN?

- Lowering the flux residues amount
- Lifting the package





Vias in the termal lug Good degassing (void supression) Lowering the gap (paste goes to vias) Pollution of other side of PCB by flux





Vias guarded by solder mask Overprint over mask Good degassing (void supression) Easier cleaning

Proper design for cleaning

- Respecting rules for optimal cleaning.....
 - By PCB designers
 - By component manufacturers
- Saves cleaning time increases cleaning capacity
- Saves energy
- Saves cleaning chemistry
- Saves deionize water consumption
- Minimize waste water treatment costs

Σ : makes assemblies more reliable for less money

QUESTIONS ?

Vladimír Sítko v.sitko@pbt-works.com